PRODUCTION OF SEMICONDUCTOR THIN FILM

Patent number:

JP9213977

Publication date:

1997-08-15

Inventor:

NEGAMI TAKAYUKI; OBARA NAOKI; NISHITANI

MIKIHIKO; WADA TAKAHIRO

Applicant:

MATSUSHITA ELECTRIC IND CO LTD

Classification:

- international:

H01L31/04; C23C14/06; H01L21/203

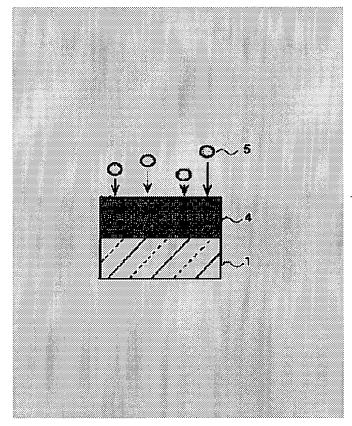
- european:

Application number: JP19960012840 19960129 Priority number(s): JP19960012840 19960129

Report a data error here

Abstract of JP9213977

PROBLEM TO BE SOLVED: To provide a production method by which the distribution of VIa-group elements Se and S in the depthwise direction of a Culn(Se,S)2 film and a Cu(In, Ga) (Se,S)2 film constituting the optical absorption layer of a. solar cell is controlled and any change is given to the forbidden band width and to provide a solar cell by which high energy conversion efficiency can be obtained by using the Culn(Se,S)2 film and Cu(In,Ga) (Se,S)2 film which are formed by this method. SOLUTION: A CulnSe2 film or Cu(ln,Ga)Se2 film 4 is formed on a substrate covered with a metallic film such as an Mo film, etc., for rear electrode, and atoms or molecules of In and S or compound molecule 5 of In-S is supplied to the surface of the film 4 so as to allow it to react therewith. As a result, the concentration of S decreases gradually from the surface of the film 4 to the depthwise direction thereof, and on the contrary, the concentration of Se increases gradually from the surface of the film 4 to the depthwise direction thereof. Thus, a Culn(Se,S)2 and a Cu(In,Ga) (Se,S)2 having such a distribution of concentration can be produced.



Data supplied from the esp@cenet database - Worldwide